

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: **Miwa KOZAWA et al.**

Group Art Unit: **1752**

Application Number: **10/629,806**

Examiner: **Sin J. Lee**

Filed: **July 30, 2003**

Confirmation Number: **9494**

For: **RESIST PATTERN THICKENING MATERIAL, PROCESS FOR
FORMING RESIST PATTERN, AND PROCESS FOR
MANUFACTURING SEMICONDUCTOR DEVICE**

Attorney Docket Number: **030923**

Customer Number: **38834**

PETITION FOR EXTENSION OF TIME

Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

April 11, 2006

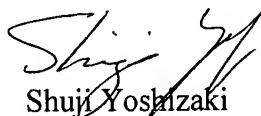
Sir:

Applicants petition the Commissioner for Patents to extend the time for response to the Office Action dated December 13, 2005 for one month from March 13, 2006 to April 13, 2006.

Attached please find a check in the amount of \$120.00 for the cost of the extension. If any additional fees are due in connection with this paper, please charge our Deposit Account No. 50-2866.

Respectfully submitted,

WESTERMAN, HATTORI, DANIELS & ADRIAN, LLP


Shuji Yoshizaki

Limited Recognition

Telephone: (202) 822-1100

Facsimile: (202) 822-1111

04/12/2006 JADD01 00000049 10629806

02 FC:1251

120.00 0P

SY/mt